

Form 1449 (Modified) Information Disclosure Statement By Applicant (Use Several Sheets if Necessary)	Atty Docket No.	Application No.:
	NIKOP037/PA0502 00/04683	To Be Assigned
	Applicant: W. Thomas Novak	Group <u>2851</u>
Filing Date	January 22, 2004	To Be Assigned

U.S. Patent Documents

Examiner Initial	No.	Patent No.	Date	Patentee	Class	Sub-class	Filing Date
HN	A	6,285,457	09/04/01	Ukaji			07/26/99
	B	6,208,407	03/27/01	Loopstra			07/13/98
	C	6,020,964	02/01/00	Loopstra, et al.			07/13/98
	D	5,917,580	06/29/99	Ebinuma, et al.			08/28/97
	E	5,416,562	05/16/95	Ota, et al.			06/22/94
HN	F	4,999,669	03/12/91	Sakamoto, et al.			07/12/89

Foreign Patent or Published Foreign Patent Application

Examiner Initial	No.	Document No.	Publication Date	Country or Patent Office	Class	Sub-class	Translation	
							Yes	No
HN	G	EP 0 793 073 A2	03/09/97	EP			X	
HN	H	EP 0 077 878 A1	04/05/83	EP			X	
	I							
	J							
	K							

Other Documents

Examiner Initial	No.	Author, Title, Date, Place (e.g. Journal) of Publication
HN	L	Patent Abstracts of Japan, Publication No. 61-196532, <i>Exposure Device</i> , Tsukamoto Izumi, filed 26/02/85.
HN	M	Patent Abstracts of Japan, Publication No. 57-183031, <i>Method For Wafer Exposure And Device Thereof</i> , Iwai Hiroshi, filed 06/05/81.
	N	
Examiner <u>H. Nguyen</u>		Date Considered <u>3/13/2005</u>

Examiner: Initial citation considered. Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.